MRS Bulletin

May 2018 Vol. 43 No. 5 www.mrs.org/bulletin

MRS MATERIALS RESEARCH SOCIETY® Advancing materials. Improving the quality of life.

Materials for advanced semiconductor memories

ALSO IN THIS ISSUE

Field-theoretic simulations: An emerging tool for probing soft material assembly

CAMBRIDGE UNIVERSITY PRESS

PARTICLE ACCELERATOR SYSTEMS



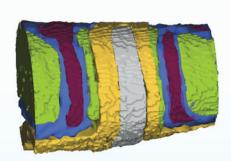
High Voltage Engineering Europa B.V.
P.O. Box 99, 3800 AB Amersfoort, The Netherlands
Tel: 31 33 4619741 • info@highvolteng.com
www.highvolteng.com



Go Big - Think Small

Atom Probe Tomography (APT) is the only material analysis technique offering extensive capabilities for simultaneous 3D imaging and chemical composition measurements at the atomic scale. Leading academic institutions use APT for groundbreaking research, and world-class manufacturers rely on APT for process improvement and materials innovation.

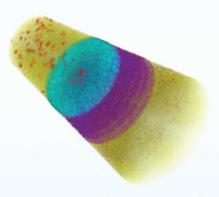
Atomic-level samples generated by APT reveal 3D chemical information not visible via other microscopy techniques.



3D volume showing the pure Si fin surrounded by the metal gate structure in a 14 nm microprocessor device



Boron segregation to a grain boundary in a Ni superalloy with carbide and boride precipitates



GaN LED device structure with Mg precipitation (red) and InGaN quantum well structure (purple)

CAMECA, the recognized world leader in atom probe development and manufacturing, offers two leading-edge APT instruments: the EIKOS™ and the LEAP® 5000.



EIKOSTM is an easier-to-use atom probe microscope, with a lower cost of ownership enabling faster development of alloys for industrial use and a deep understanding of materials for research applications.



The LEAP™ 5000 is CAMECA's cutting-edge atom probe microscope, offering superior detection efficiency and yield across a wide variety of metals, semiconductors and insulators.

METEK®

MATERIALS ANALYSIS DIVISION

Atom Probe Tomography is the only microanalytical technique that can provide full insight into the nanostructures of your materials. See more, learn more, make more. Accomplish big things by thinking small.

www.cameca.com cameca.info@ametek.com

Get a free guide to atom probe tomography at http://bit.ly/EKBAPT

MATERIALS FOR ADVANCED SEMICONDUCTOR MEMORIES



Advanced memory—Materials for a new era of information technology

Cheol Seong Hwang and Bernard Dieny, Guest Editors



Future of dynamic random-access memory as main memory

Seong Keun Kim and Mihaela Popovici



Ferroelectric hafnium oxide for ferroelectric random-access memories and ferroelectric field-effect transistors

> Thomas Mikolajick, Stefan Slesazeck, Min Hyuk Park, and Uwe Schroeder



Topological memory using phase-change materials

Junji Tominaga



Materials for spin-transfer-torque magnetoresistive random-access memory

> Shinji Yuasa, Kazuhiro Hono, Guohan Hu, and Daniel C. Worledge



Purely electronic nanometallic resistance switching random-access memory

> Yang Lu, Jung Ho Yoon, Yanhao Dong, and I.-Wei Chen



Scanning probe-type data storage beyond hard disk drive and flash memory

Yasuo Cho and Seungbum Hong

TECHNICAL FEATURE



Field-theoretic simulations: An emerging tool for probing soft material assembly

Glenn H. Fredrickson and Kris T. Delaney

DEPARTMENTS



NEWS & ANALYSIS

318 Materials News

- Hydrophobic and hydrophilic surfaces hold tight through chemical silane bonds Hortense Le Ferrand
- E-skin sensor self-heals and can be recycled Boris Dyatkin
- Atomic thin layers of Sn exhibit superconductivity Tianyu Liu
- Stretchable organic electronics on skin monitors health Rahim Munir
- Field-effect transistor is powered by solar energy Ahmad R. Kirmani
- Seashells inspire thin-film heater composite using silver nanowires Boris Dyatkin
- Soft robots achieve muscle-like performance, selfhealing through electrohydraulic coupling Hortense Le Ferrand

325 Science Policy

 US Academies examine open science and reproducibility

Jennifer A. Nekuda Malik

 European Commission to set up ethics committee on artificial intelligence



DIVERSITY IN MS&E

379 Representation of Native Americans in US science and engineering faculty

Donna J. Nelson

Feature Editor: Lynnette D. Madsen



SOCIETY NEWS

- 384 Taking IMOS on the road—to Greece Vasiliki Kioupi
 - International School of Materials for Sustainable Development & Energy first course to be held July 7-13 in Italy
 - In memoriam: Walter Lyons Brown



ON THE COVER

Materials for advanced semiconductor memories. The need for emerging and new memory technologies with nonvolatility and low power-consumption performance continues to rapidly increase, while improvements in current dvnamic random-access memory and NAND flash are simultaneously being pursued. In both new and current memories, material innovation is of central importance. In this issue of MRS Bulletin,

recent advances in both of these critical areas are reviewed, with a focus on emerging and novel materials for disruptive memory concepts. The cover shows automated electrical testing of spintronics devices used as memory fabricated at SPINTEC, Grenoble, France, See the technical theme that appears on page 330.



FEATURES

328 Beyond the Lab

Food for thought—edible soft robotic candy actuators Lori A. Wilson

388 **Historical Note**

Indigenous Amazonian potteries as early reinforced ceramics Hortense Le Ferrand

389 Book Reviews

- Introduction to Magnetic Random-Access Memory Bernard Dieny, Ronald B. Goldfarb, and Kyung-Jin Lee Reviewed by Joana Vaz Pinto
- Electron Nano-Imaging: Basics of Imaging and **Diffraction for TEM and STEM**

Nobuo Tanaka Reviewed by Lourdes Salamanca-Riba

2D Nanoelectronics: Physics and Devices of **Atomically Thin Materials** Mircea Dragoman and Daniela Dragoman

391 Posterminaries

The potential of robots for humankind Steve Moss

Reviewed by K. Kamala Bharathi

ADVERTISERS IN THIS ISSUE	Page No
American Elements	
CAMECA Instruments, Inc	313
Rigaku Corporation	333

www.mrs.org/bulletin www.mrs.org/energy-quarterly www.mrs.org/mymrs http://journals.cambridge.org mrsbulletin-rss y @mrsbulletin





EDITORIAL OFFICE 506 Keystone Drive, Warrendale, PA 15086-7573 USA Bulletin@mrs.org tel 724.779.2747 fax 724.779.8313 www.mrs.org

About the Materials Research Society

The Materials Research Society (MRS), a not-for-profit scientific association founded in 1973 and headquartered in Warrendale, Pennsylvania, USA, promotes interdisciplinary materials research. Today, MRS is a growing, vibrant, member-driven organization of over 16,000 materials researchers spanning over 80 countries, from academia, industry, and government, and a recognized leader in the advancement of interdisciplinary materials research.

The Society's interdisciplinary approach differs from that of single-discipline professional societies because it promotes information exchange across many scientific and technical fields touching materials development. MRS conducts three major international annual meetings and also sponsors numerous single-topic scientific meetings. The Society recognizes professional and technical excellence and fosters technical interaction through University Chapters. In the international arena, MRS implements bilateral projects with partner organizations to benefit the worldwide materials community. The Materials Research Society Foundation helps the Society advance its mission by supporting various projects and initiatives.

2018 MRS BOARD OF DIRECTORS

President Sean J. Hearne, Sandia National Laboratories, USA Immediate Past President Susan Trolier-McKinstry,

The Pennsylvania State University, USA

Vice President and President-Elect Michael R. Fitzsimmons.

Oak Ridge National Laboratory and The University of Tennessee, USA Secretary Eric A. Stach, University of Pennsylvania, USA
Treasurer David J. Parrillo, The Dow Chemical Company, USA Executive Director Todd M. Osman, Materials Research Society, USA

Griselda Bonilla, IBM T.J. Watson Research Center, USA Li-Chyong Chen, National Taiwan University, Taiwar Matt Copel, IBM T.J. Watson Research Center, USA Paul S. Drzaic, Apple, Inc., USA Dawnielle Farrar-Gaines, Johns Hopkins University, USA Yury Gogotsi, Drexel University, USA

Claudia Gutiérrez-Wing, Instituto Nacional de Investigaciones Nucleares, Mexico Young-Chang Joo, Seoul National University, South Korea

Lincoln J. Lauhon, Northwestern University, USA

Paul C. McIntyre, Stanford University, USA Christopher A. Schuh, Massachusetts Institute of Technology, USA Rachel A. Segalman, University of California, Santa Barbara, USA

Magaly Spector, The University of Texas at Dallas, USA Molly M. Stevens, Imperial College London, UK

Ehrenfried Zschech, Fraunhofer Institute for Ceramic Technologies

and Systems, Germany

MRS OPERATING COMMITTEE CHAIRS

Academic Affairs Bruce M. Clemens, Stanford University, USA Awards Albert Polman, FOM Institute AMOLF, The Netherlands Awards Albert Polinian, FOM Institute Alword, The Netherlands Government Affairs David P. Norton, University of Florida, USA Meetings Terry Aselage, Sandia National Laboratories, USA Member Engagement Sossina M. Haile, Northwestern University, USA Public Outreach Elizabeth Kupp, The Pennsylvania State University, USA Publications Shefford P. Baker, Cornell University, USA

MRS HEADQUARTERS

Todd M. Osman, Executive Director J. Ardie Dillen, Director of Finance and Administration Damon Dozier, Director of Government Affairs Patricia Hastings, Director of Meetings Activities Eileen M. Kiley, Director of Communications

Editor

Gopal R. Rao, rao@mrs.org

Managing Editor

Lori A. Wilson, lwilson@mrs.org

News Editor

Judy Meiksin, meiksin@mrs.org

Technical Editor

Lisa C. Oldham, oldham@mrs.org

Editorial Assistants

Michelle S. Raley, raley@mrs.org Mary Wilmoth

Associate Technical Editor

Carol Tseng

Production/Design

Michael P. Moran, Rebecca Tokarczyk, Felicia Turano, and TNQ

Associate Production Editor

Katie Wurtzel

Principal Development Editor

Elizabeth L. Fleischer

Director of Communications

Eileen M. Kiley

Guest Editors

Cheol Seong Hwang and Bernard Dieny

Special Consultant

Angelika Veziridis

Energy Quarterly

Andrea Ambrosini (Chair). Monika Backhaus, Kristen Brown, David Cahen, Russell R. Chianelli, George Crabtree, Elizabeth A. Kócs, Shirley Meng, Sabrina Sartori, Anke Weidenkaff, M. Stanley Whittingham, and Steve M. Yalisove

Advertising/Sponsorship
Mary E. Kaufold, kaufold@mrs.org Donna L. Watterson, watterson@mrs.org

Member Subscriptions

Michelle Judt, judt@mrs.org

Non-Member Subscriptions

subscriptions_newyork@cambridge.org

EDITORIAL BOARD

Fiona C. Meldrum (Chair), University of Leeds, UK Ilke Arslan, Pacific Northwest National Laboratory, USA

V.S. Arunachalam, Center for Study of Science, Technology & Policy, India

N. (Balu) Balasubramaniam, Bangalore, India (retired)

Christopher J. Bettinger, Carnegie Mellon University, USA

Tommie Kelley, 3M, USA

Igor Lubomirsky, Weizmann Institute, Israel

Amit Misra, University of Michigan, USA

Steven C. Moss, The Aerospace Corporation, USA (retired)

Julie A. Nucci, Cornell University, USA

Linda J. Olafsen, Baylor University, USA Boaz Pokroy, Technion-Israel Institute of Technology, Israel

Zhiwei Shan, Xi'an Jiaotong University and Hysitron, China

James W. Stasiak, HP Inc., USA

Carol Trager-Cowan, University of Strathclyde, UK

Eric Werwa, Washington, DC, USA

M. Stanley Whittingham, Binghamton University, The State University of New York, USA

Steve M. Yalisove, University of Michigan, USA

VOLUME ORGANIZERS

2018 Karsten Albe, Technische Universität Darmstadt, Germany Hiroshi Funakubo, Tokyo Institute of Technology, Japan Michael Hickner, The Pennsylvania State University, USA Bethanie Stadler, University of Minnesota, USA

2019 Craig B. Arnold, Princeton University, USA

Claus Daniel, Oak Ridge National Laboratory and The University of Tennessee, Knoxville, USA

Seung Min Han, Korea Advanced Institute of Science and Technology, South Korea Gabriel Montaño, Los Alamos National Laboratory/Northern Arizona University, USA

MRS Bulletin (ISSN: 0883-7694, print; ISSN 1938-1425, online) is published monthly by the Materials Research Society, 506 Keystone Drive, Warrendale, PA 15086-7573. © 2018 Materials Research Society. Permission required to reproduce content. Periodical postage paid at New York, NY, and at additional mailing offices. POSTMASTER: Send address changes to MRS Bulletin in care of the Journals Department, Cambridge University Press, 100 Brook Hill Drive, West Nyack, NY 10994-2113, USA. Printed in the U.S.A.
Membership in MRS is \$130 annually for regular members, \$25 for students, and includes an electric subscription of MRS Bulletin. Print subscriptions are available to MRS members for an additional \$25. Individual member subscriptions are for personal use only. Non-member subscription rates are \$560 (USD) for one calendar year (12 issues). Requests from subscribers

for missing journal issues will be honored without charge only if received within six months of the issue's actual date of publication.

MRS Bulletin is included in Current Contents®/Engineering, Computing, and Technology; Current Contents®/Physical, Chemical, and Earth Sciences, the SciSearch® online database,
Research Alert®, Science Citation Index®, and the Materials Science Citation Index™. Back volumes of MRS Bulletin are available on microfiche through University Microfilms Inc., 300 North Zeeb Road, Ann Arbor, MI 48106, USA,

Authors of each technical article appearing in MRS Bulletin are solely responsible for all content in their article(s), including accuracy of the facts, statements, and citing resources. Facts and opinions are solely the personal statements of the respective authors and do not necessarily represent the views of the editors, the Materials Research Society, or Cambridge University Press.

Send Letters to the Editor to Bulletin@mrs.org. Include your name, affiliation, and full contact information.



Submission Deadline—June 1, 2018

Early Career Scholars in Materials Science 2019

The Fourth Annual *JMR* Issue to promote outstanding research by future leaders in materials science

This fourth Annual Issue invites full length research and review articles by materials researchers, who have completed their PhD degree but not yet achieved full professorship at the time of submission, for peer review and publication in the January 2019 issue. PhD students are not eligible to submit. The Annual Issue provides a unique opportunity to be highlighted and promoted early in one's research career. To increase attention to these papers, this issue will be published on an **open access** basis. Although some papers may have multiple authors, only the Early Career Scholar submitting the paper will be identified with a photo and brief bio when the paper is published. Authors from around the world are invited to submit papers that span the topical coverage of *JMR* including advanced ceramics, metals, polymers, composites, and combinations thereof related to energy, electrical, magnetic, optical, and structural properties and related applications and reporting on:

- Advanced characterization methods and techniques
- Computational materials science when coupled with experimentation
- · Fundamental materials science
- Interfacial science as relates to material process understanding and improvements
- Material property enhancements through advances in materials processing
- Material property enhancements through material design (especially Materials Genome related)
- Material combinations and design that improve system performance
- Nanoscience and nanotechnology

LEAD EDITORS

Gary L. Messing, The Pennsylvania State University, USA Susmita Bose, Washington State University, USA Jürgen Eckert, Montanuniversität Leoben, Austria Linda S. Schadler, Rensselaer Polytechnic Institute, USA

MANUSCRIPT SUBMISSION

To be considered for the issue, the Early Career Scholar must not yet be a full professor at the time of submission. Also, the manuscript must report new and previously unpublished results. Review articles are invited but must be approved by the issue editors before submission (see www.mrs.org/jmr-manuscript-types/ regarding review articles). Manuscripts must be submitted via the *JMR* electronic submission system by **June 1, 2018**. Manuscripts submitted after this deadline will not be considered for the issue due to time constraints on the review process. Submission instructions can be found at www.mrs.org/jmr-instructions. Please select "ANNUAL ISSUE: *Early Career Scholars in Materials Science 2019*" as the manuscript type. **Note our manuscript submission minimum length of 3250 words, with at least 6 and no more than 10 figures and tables.** (Additional figures and tables may be submitted as supplemental material.) All manuscripts will be reviewed in a normal but expedited fashion. Papers submitted by the deadline and subsequently accepted will be published in the Special Issue. Other manuscripts that are acceptable but cannot be included in the issue will be scheduled for publication in a subsequent issue of *JMR*.

Papers must be accompanied by a photo (uploaded separately as a high resolution TIF or EPS file) and 200–300 word bio of the Early Career Scholar only. These materials must be submitted along with the original submission of the paper.

